

### Supplementary Information

#### Flexible transparent and hydrophobic SiNCs/PDMS coatings for anti-counterfeit applications

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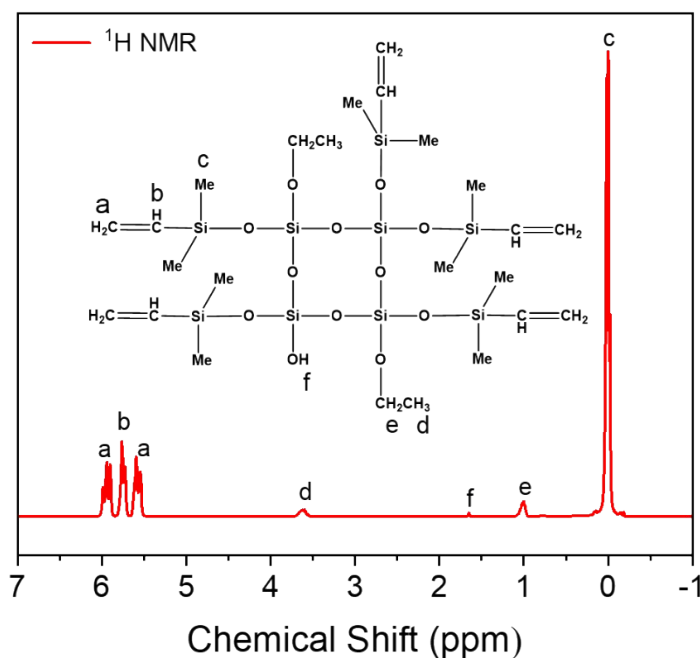


Figure S1. <sup>1</sup>H NMR of V-MQ.

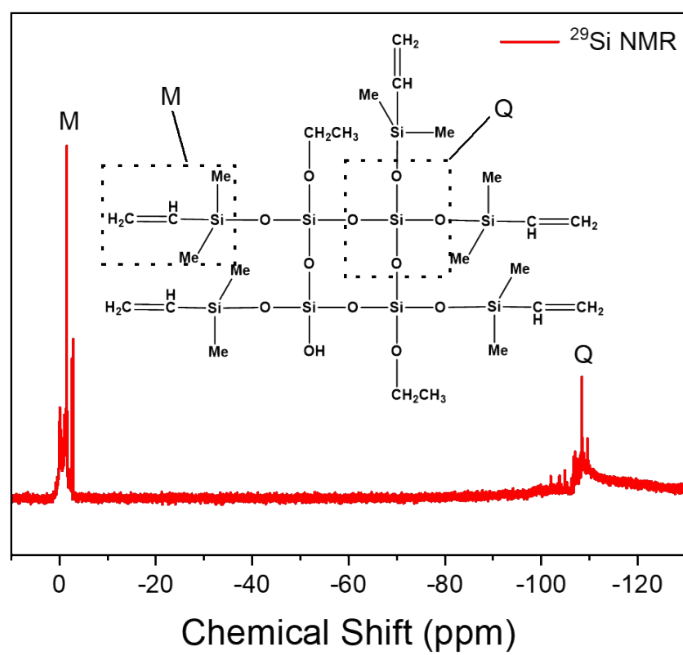


Figure S2.  $^{29}\text{Si}$  NMR of V-MQ.

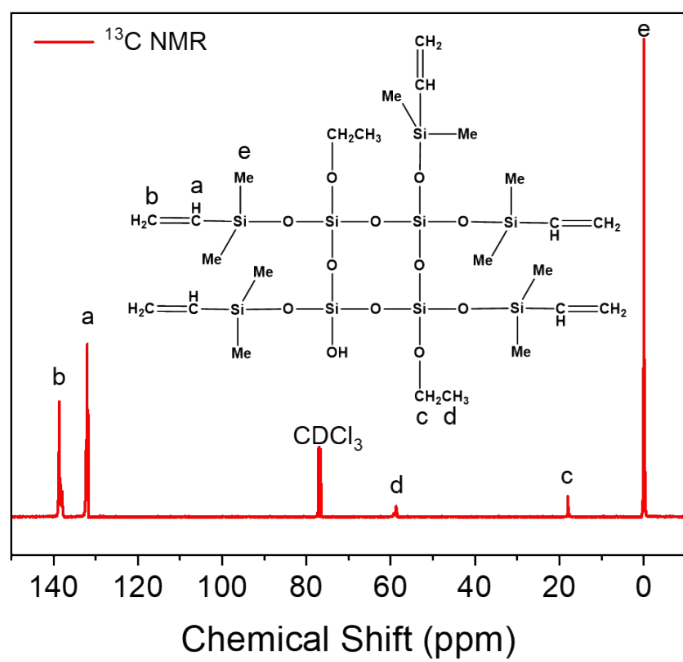


Figure S3.  $^{13}\text{C}$  NMR of V-MQ.

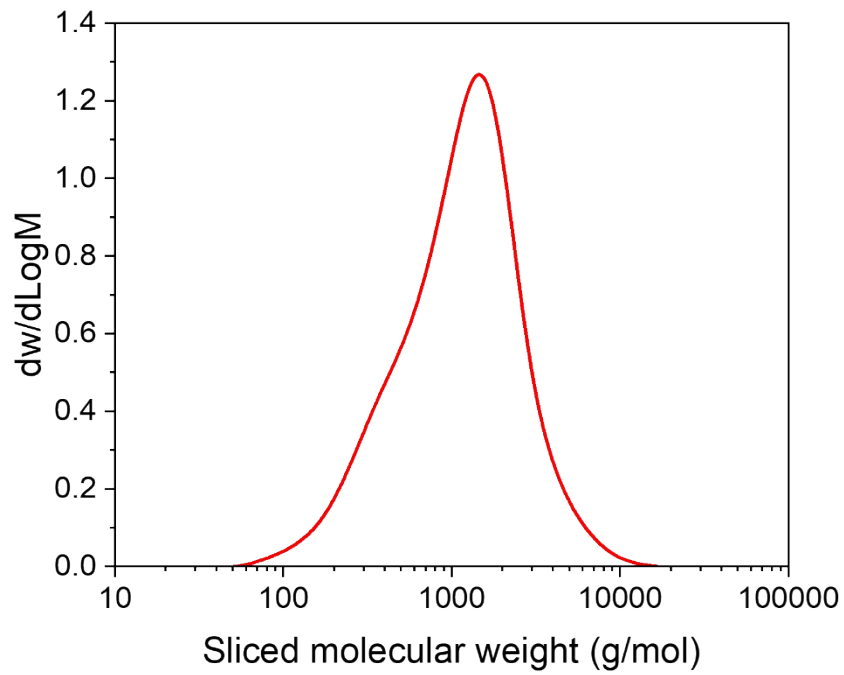


Figure S4. GPC of V-MQ.

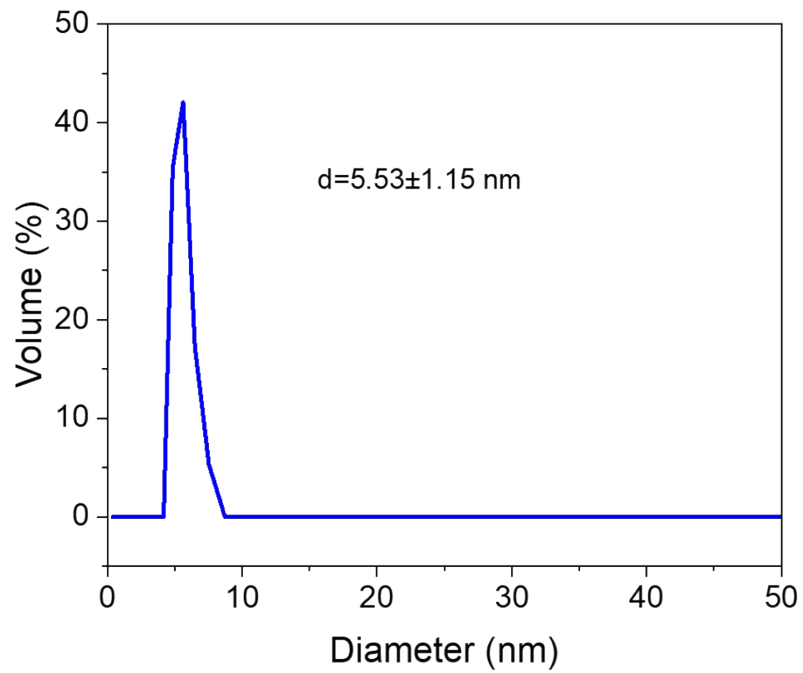
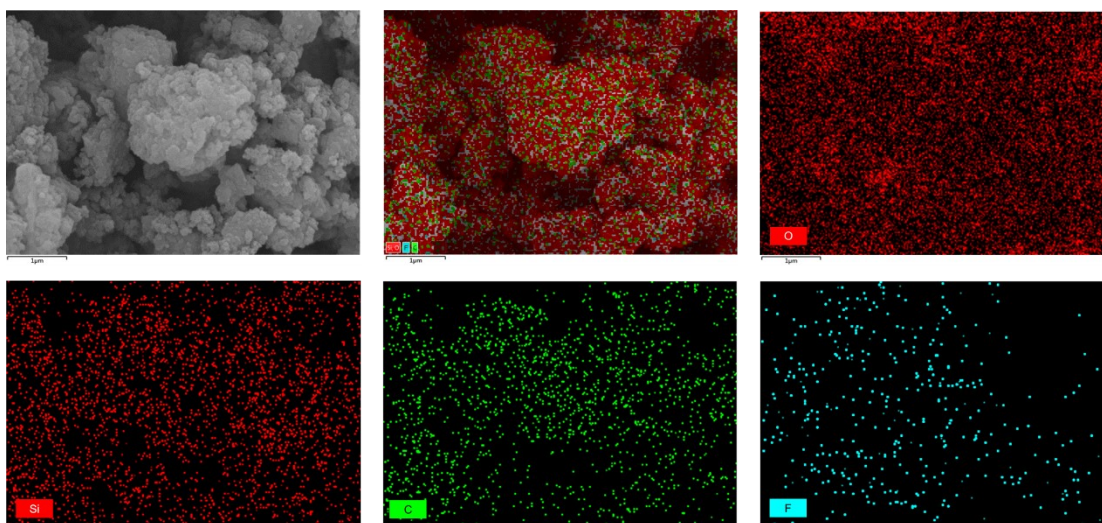
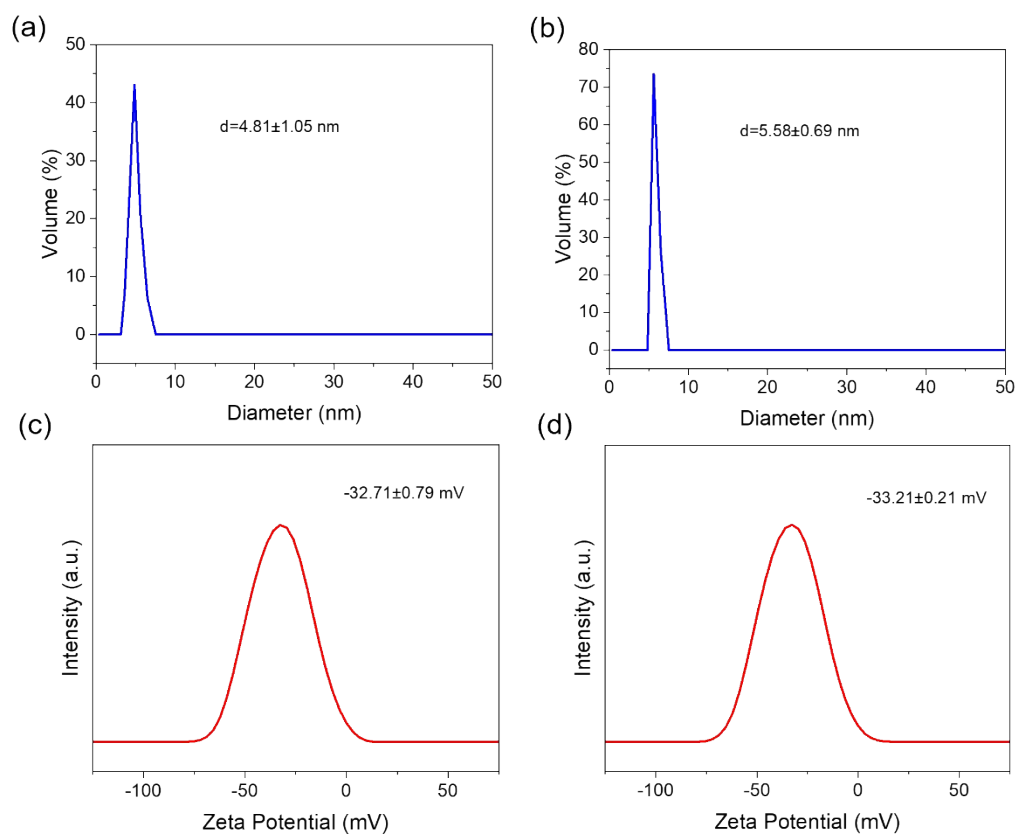


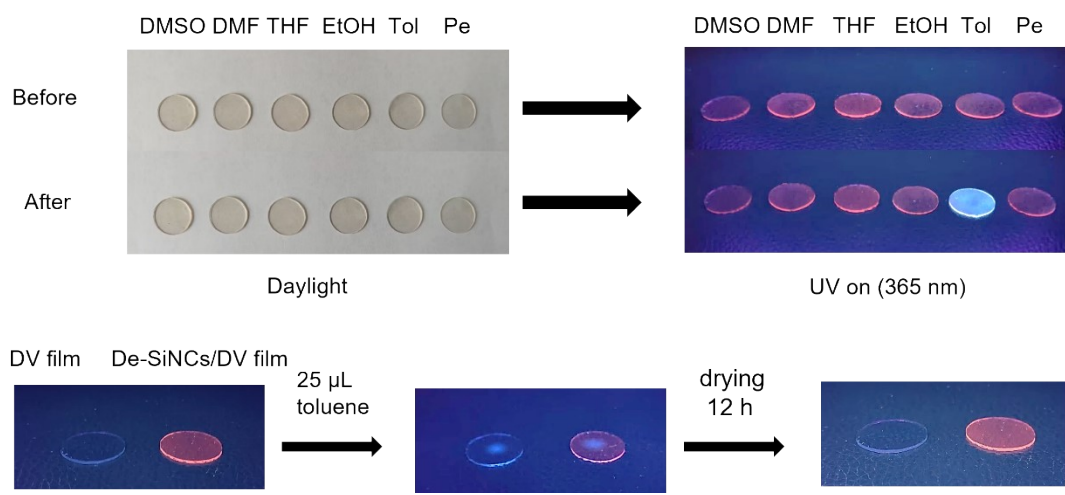
Figure S5. DLS analysis diameters of the De-SiNCs dispersed in petroleum ether.



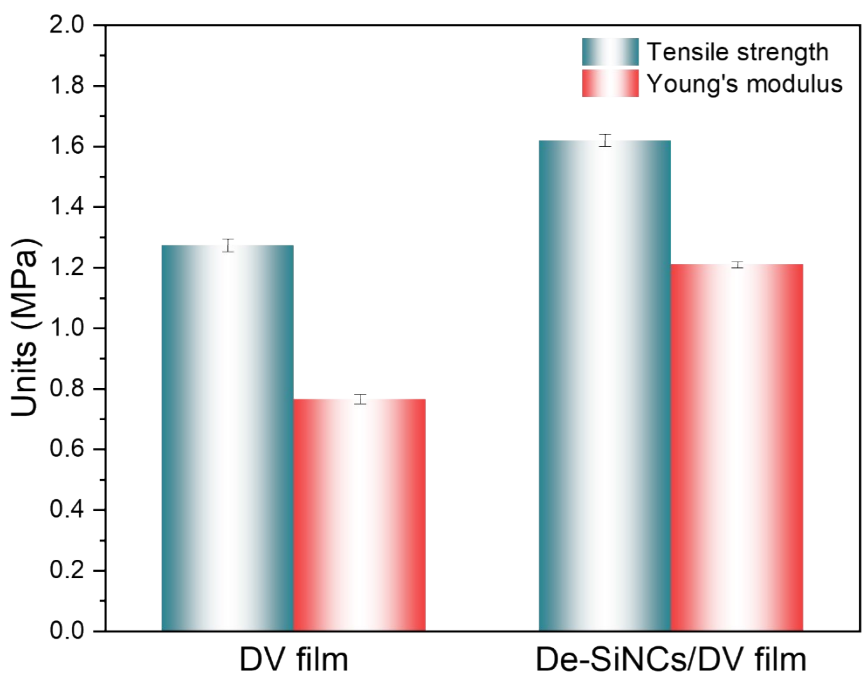
**Figure S6.** EDS of the De-SiNCs (scale of 1  $\mu\text{m}$ ).



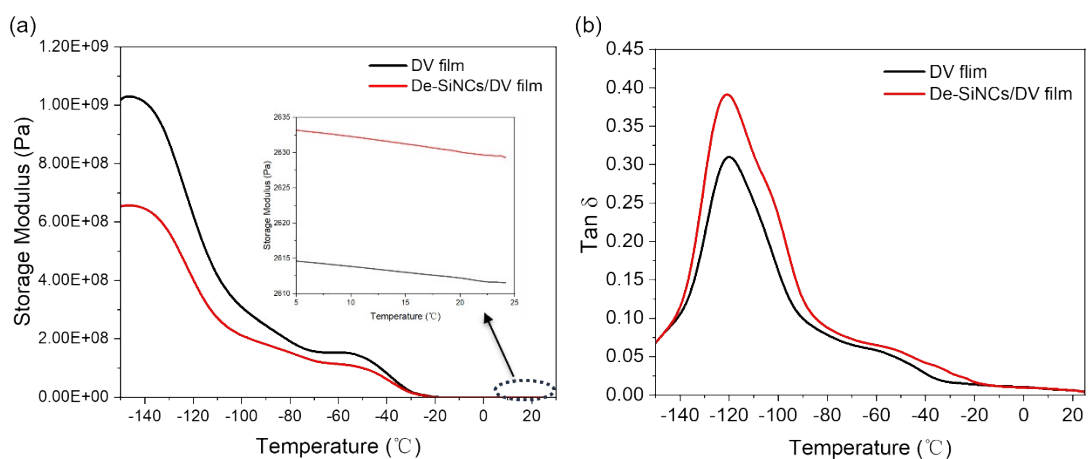
**Figure S7.** (a-b) Changes in particle size and (c-d) surface potential of De-SiNCs before and after storage for 7 days.



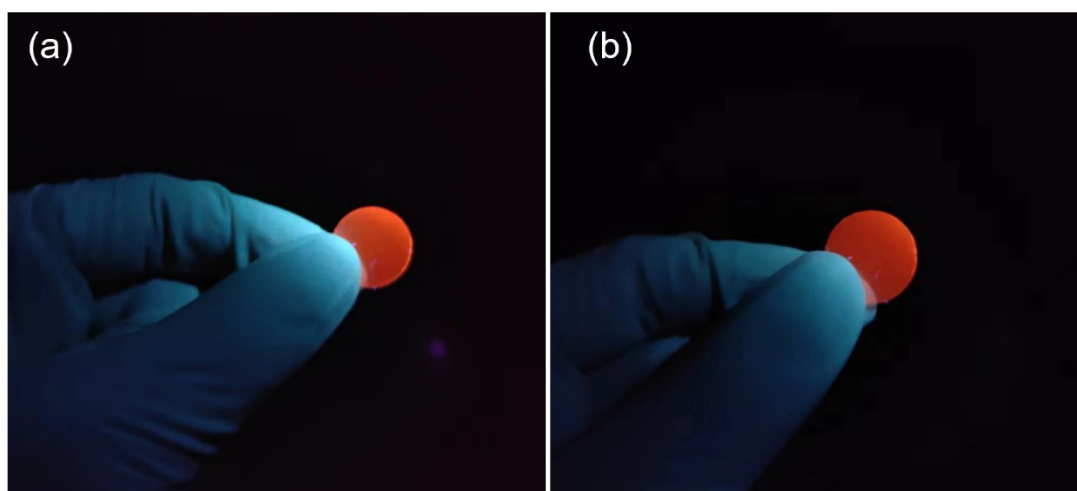
**Figure S8.** Experimental photo of solvent resistance test of DV and De-SiNCs/DV films.



**Figure S9.** Tensile strength and Young's modulus of DV and De-SiNCs/DV films.



**Figure S10.** DMA curves of the DV and De-SiNCs/DV films. (a) Storage Modulus. (b) Tan  $\delta$ .



**Figure S11.** Fluorescence photographs of De-SiNCs/DV films (a) before and (b) after storage for 300 days.

**Table S1.** Important characterization data for degradation of DV and De-SiNCs/DV films.

Sample	Temperature for 5% weight loss (°C)	Temperature for 20% weight loss (°C)	Temperature at maximum degradative rate (°C)	Residue at 800 °C (%)	$\Delta E^a$ (kJ/mol)
DV film	439.3	514.1	495.0	52.5	45.97
De-SiNCs/DV film	444.9	525.5	605.0	36.4	97.63

<sup>a</sup> Activation energy for the maximum degradation step of DV and De-SiNCs/DV films under a constant heat rate of 10 °C/min.